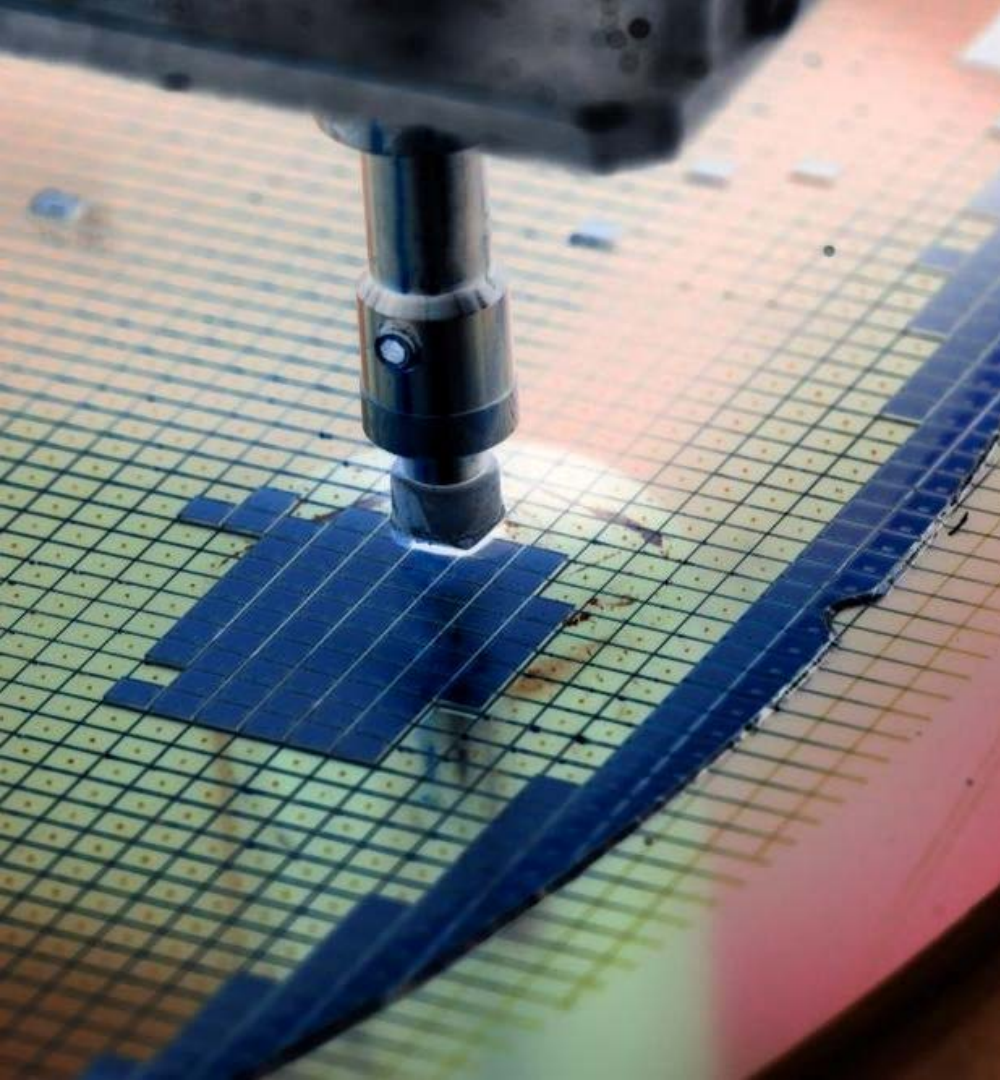


**DEVELOPMENT OF NEW MEASUREMENT CAPABILITIES
BASED ON PHOTOEMISSION ELECTRON MICROSCOPY AND
ELECTRICAL MEASUREMENTS**

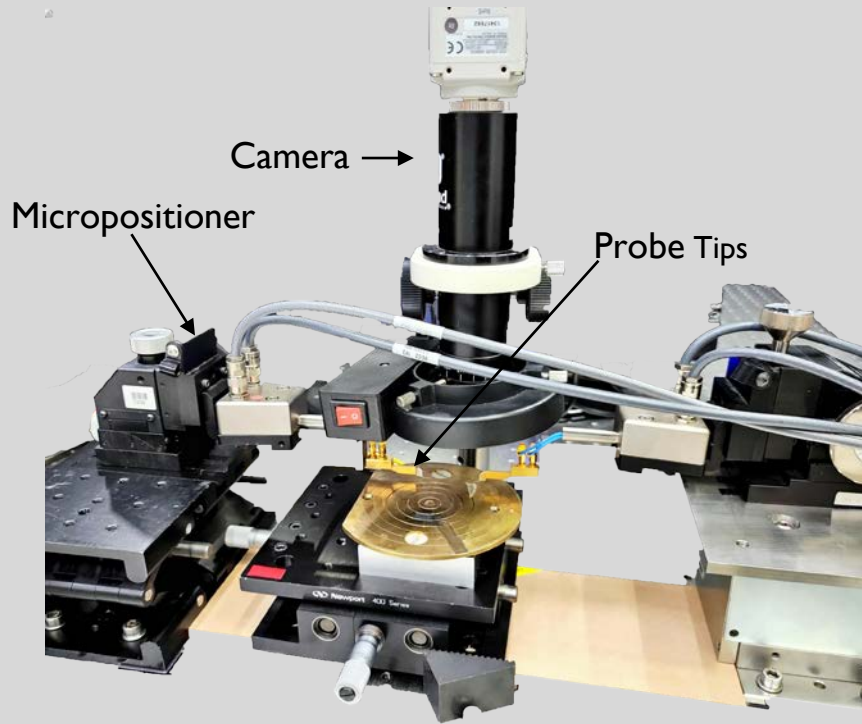
Div Chamria
Colgate University
Advisor: Dr. Sujitra Pookpanratana
Nanoscale Device Characterization Division, NIST



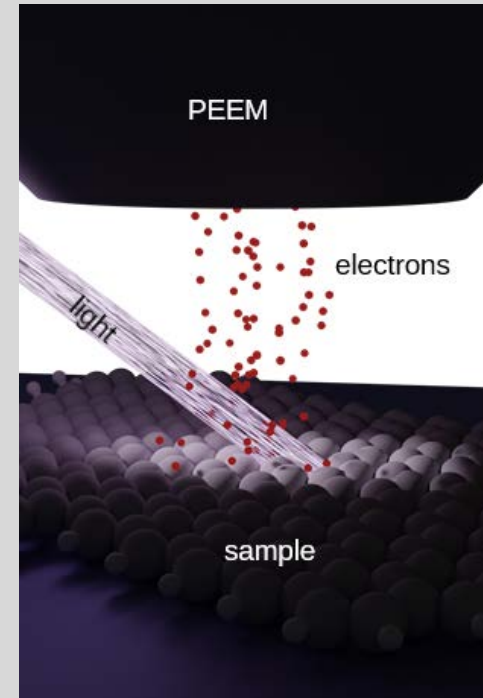
Motivation

- Semiconductors
- Measuring and standardizing electronic properties
- Enhancing capabilities of instruments

Methods of Sample Characterization



Electrical Measurements



Credit: Niefind Falk

Photoemission Electron Microscopy

The Instruments



Yokogawa 7651

DC Power Source – Outputs **voltage** or **current**



Keithley 6514

System Electrometer – Measures **current**, **voltage** and **resistance**



Agilent E4980

Precision LCR Meter – Sweeps through voltage/frequency while measuring **impedance**

Source Measurement Unit

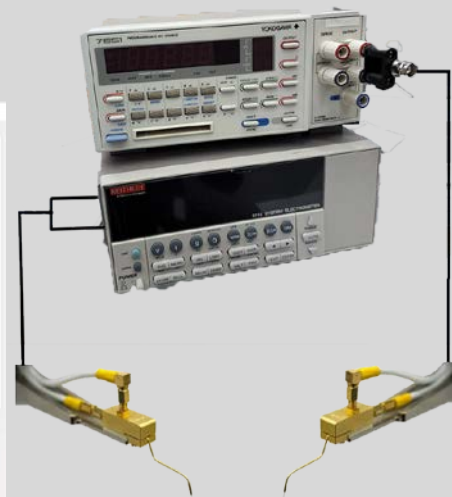
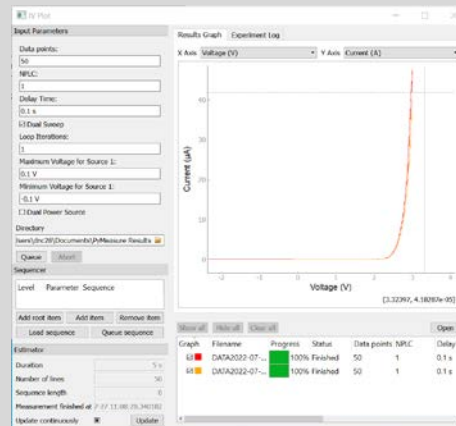
[illegible]

The instrument API is controlled using SCPI commands.

The existing libraries were modified to add necessary functionality and controls to each instrument.

Python code was used to control instruments and add a graphical user interface.

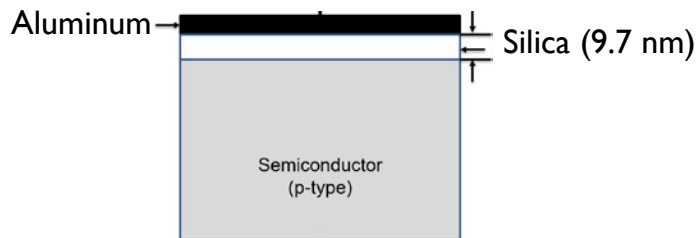
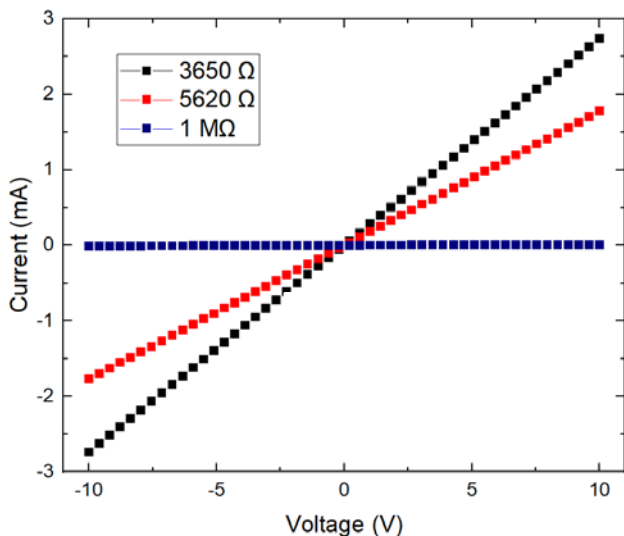
The instruments were connected and tested with various devices to ensure reliability.



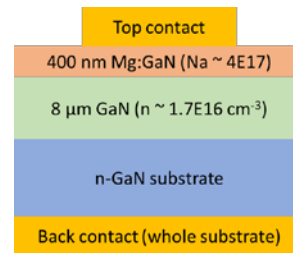
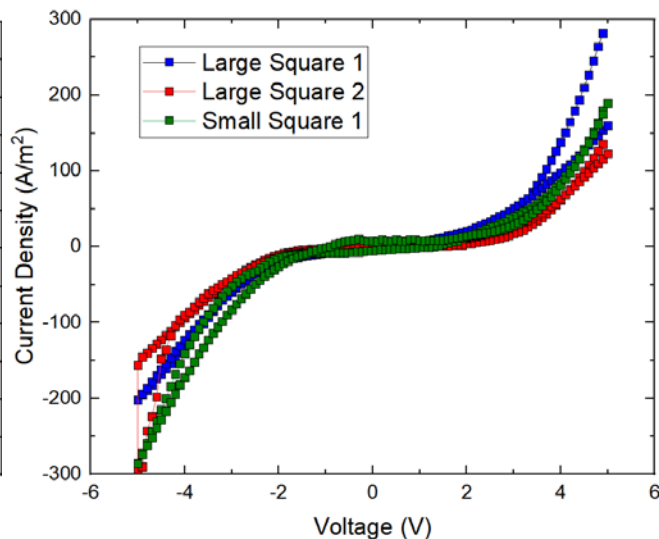
Source Measurement Unit Calibration



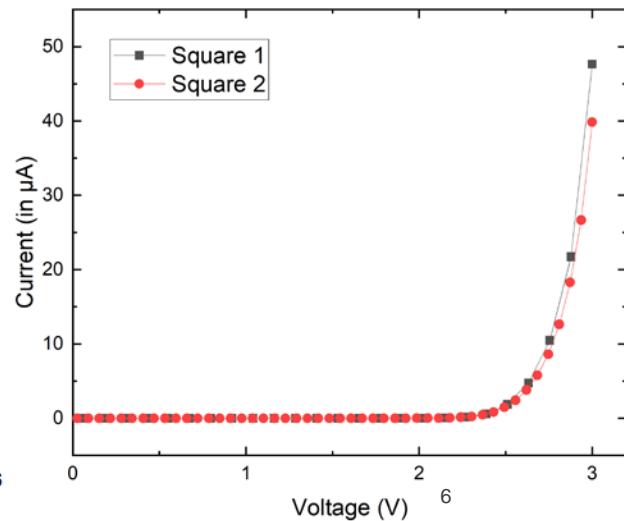
Commercial Resistors



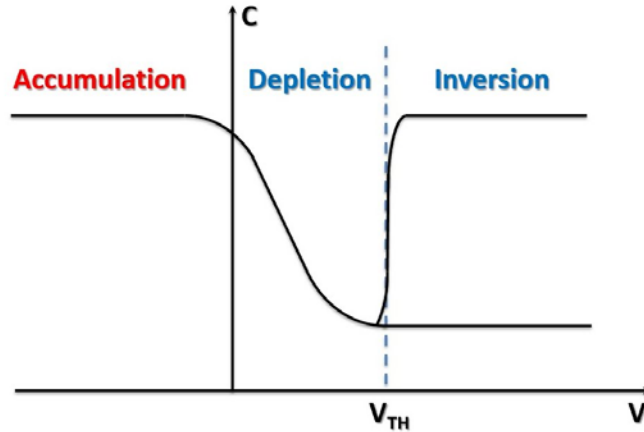
MOS Device



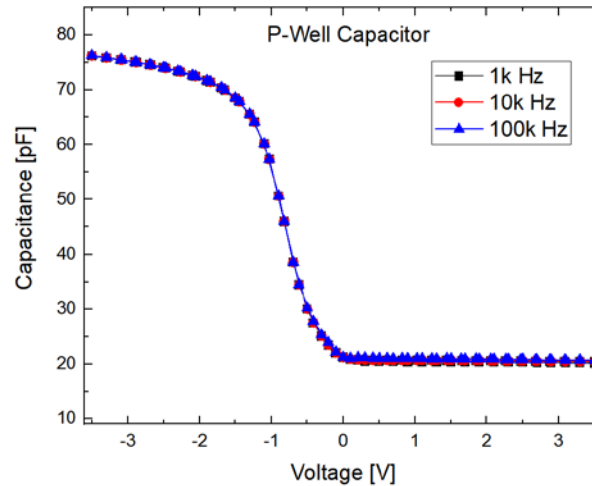
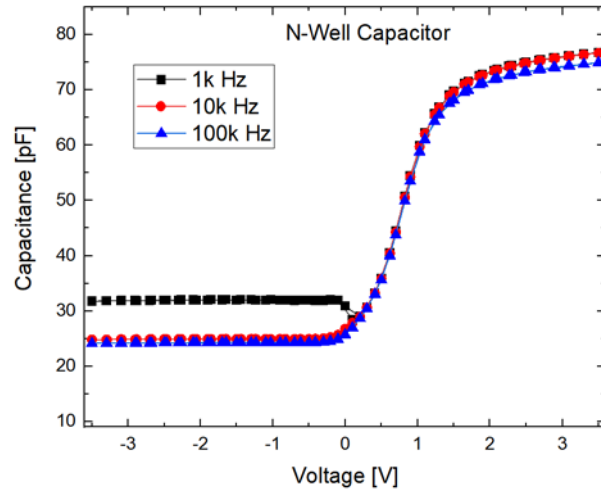
GaN Diode



C-V Characteristics



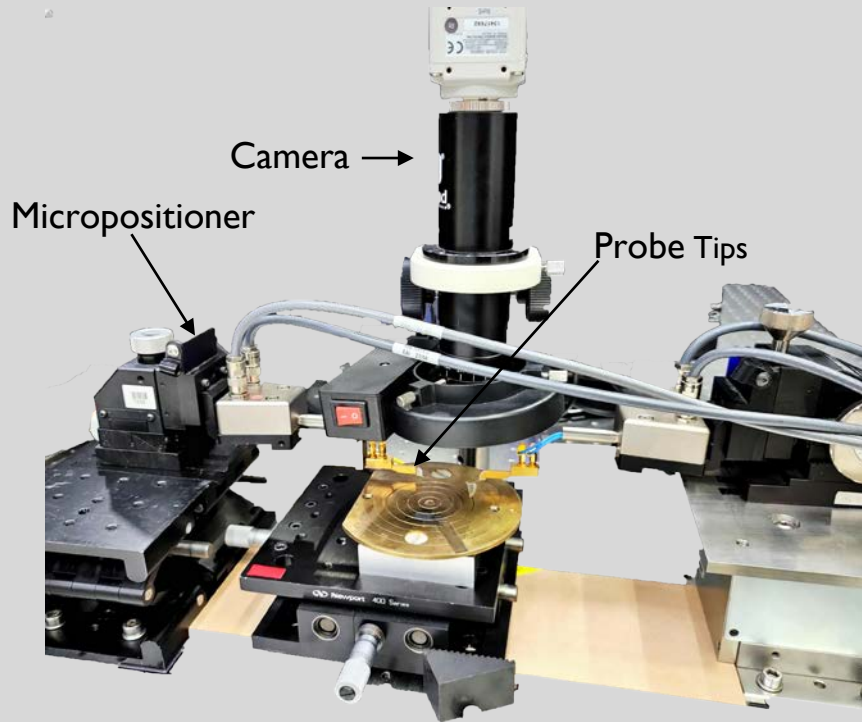
1m)



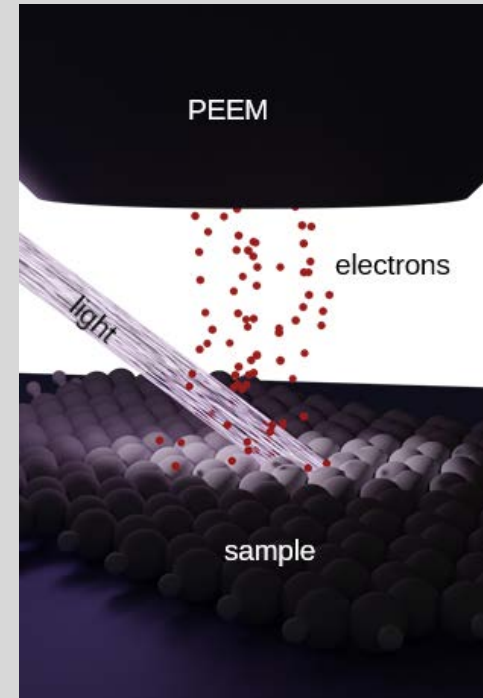
LCR Meter

- Performing CV measurements
- Expected depletion behavior
- Testing and Results

Methods of Sample Characterization

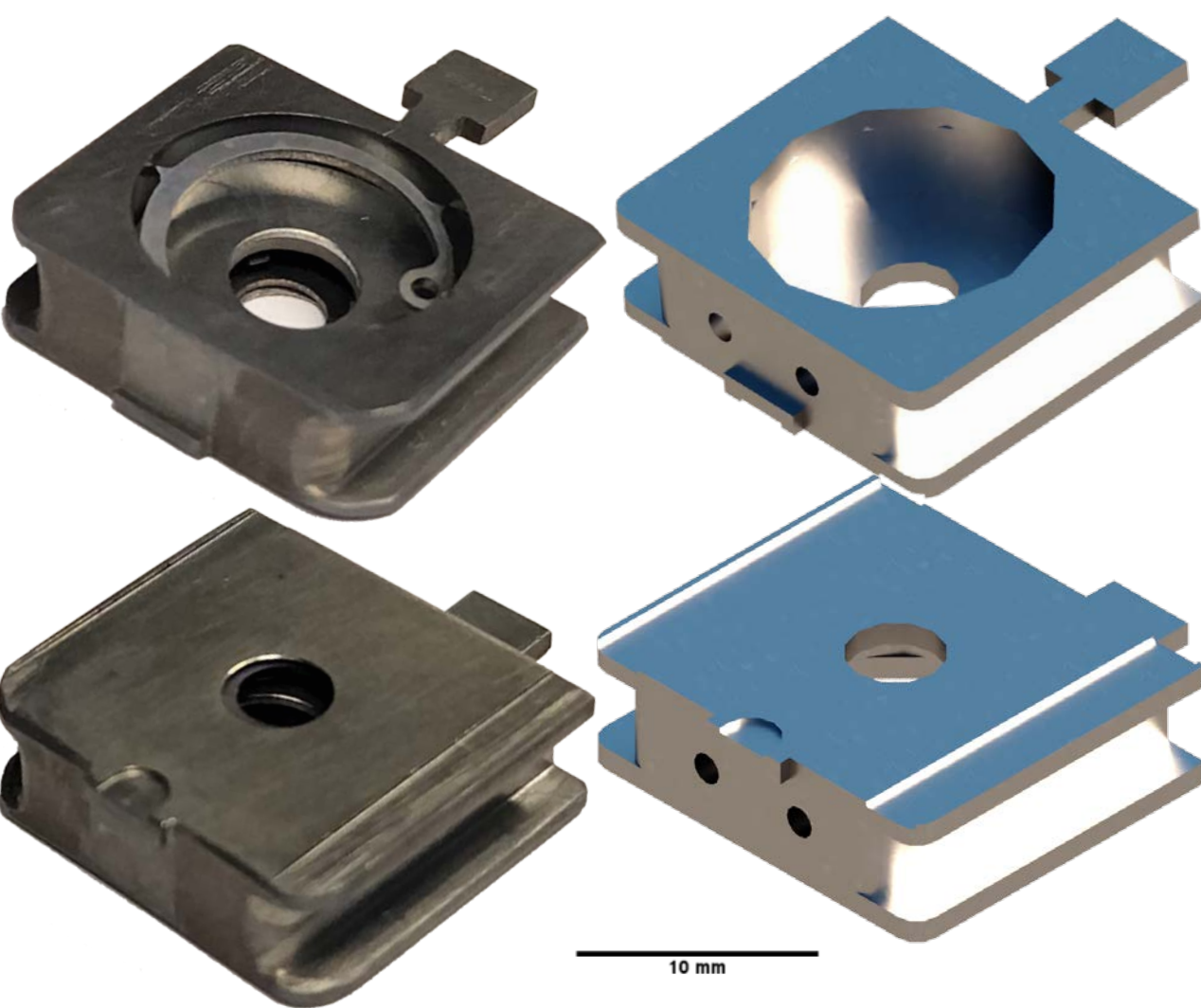


Electrical Measurements



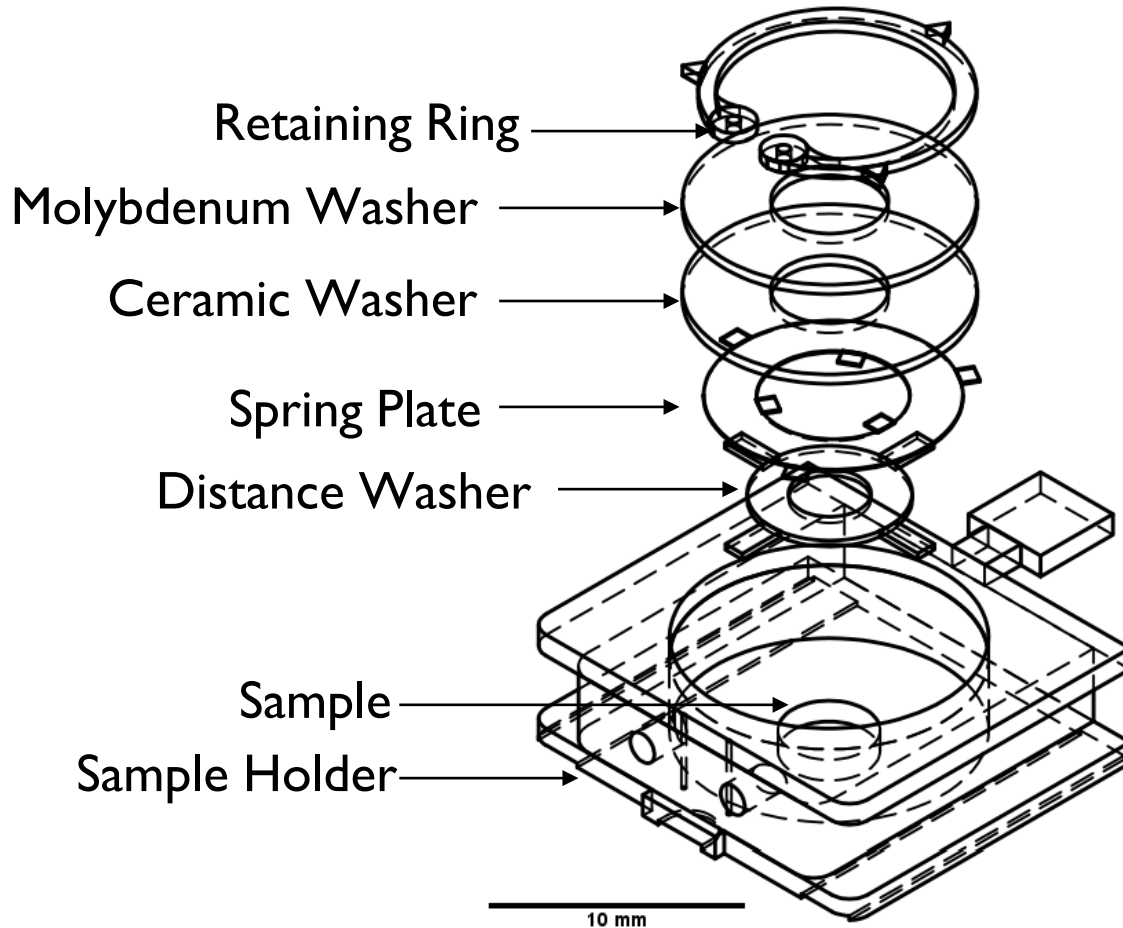
Credit: Niefind Falk

Photoemission Electron Microscopy



PEEM – Sample Holder

- AutoCad
- 6 Separate Components
- PEEM Shuttle and Electrical Contact
- Operando Electrical Measurements

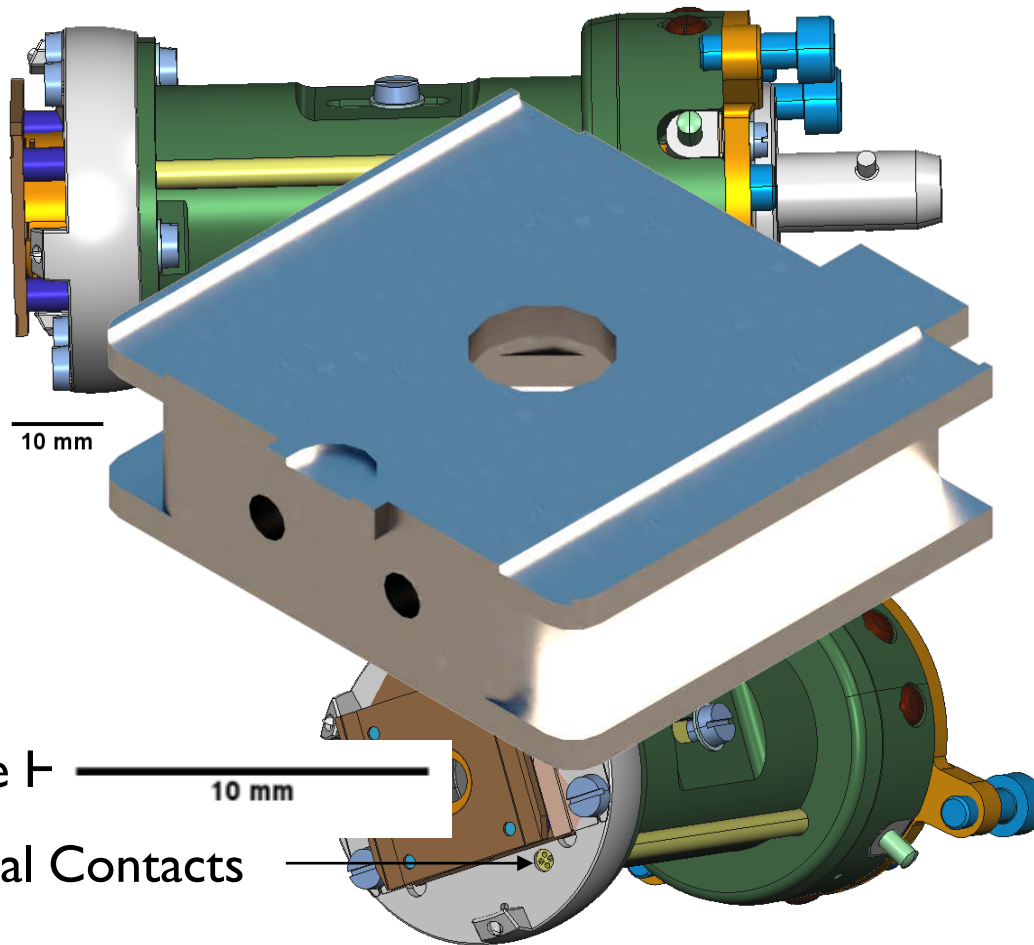


PEEM – Sample Holder

- AutoCad
- 6 Separate Components
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- Operando Electrical Measurements

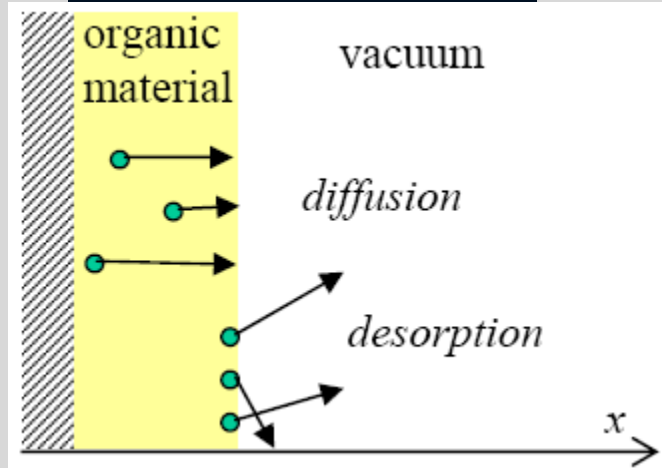
PEEM – Sample Holder

- AutoCad
- 6 Separate Components
- PEEM Shuttle and Electrical Contact
- Operando Electrical Measurements



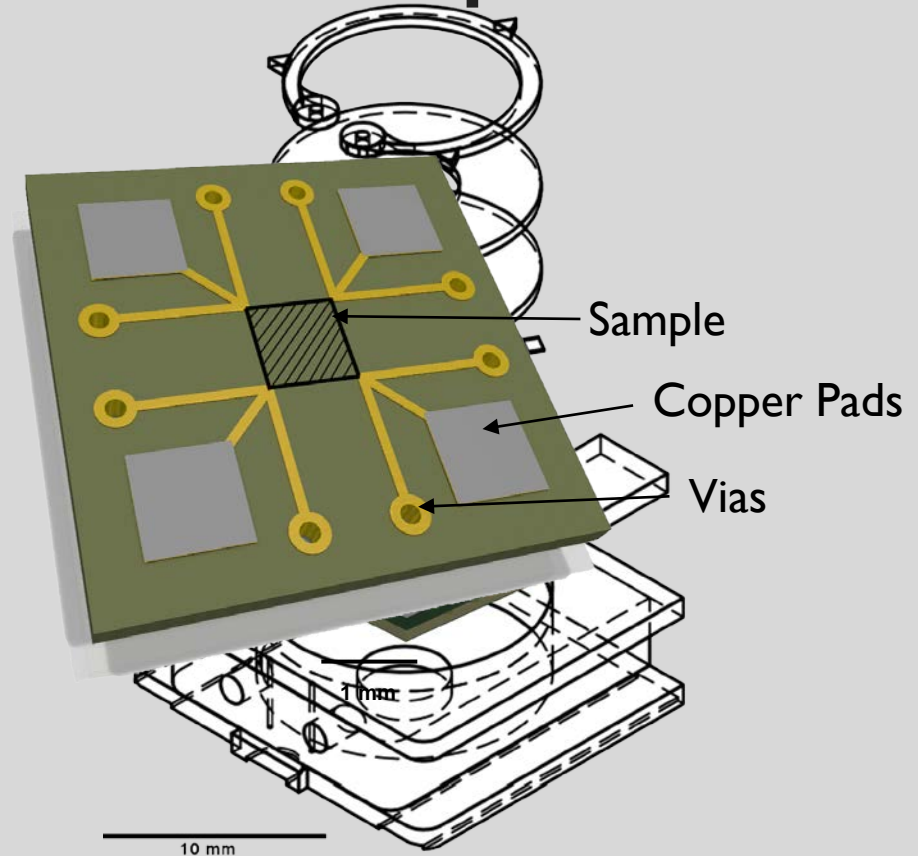
Printed Circuit Board for Sample Holder

- Purpose
- Symmetrical
- Ultra High Vacuum compatible materials
- Designed for sample holder



Roussel et al., 2009

Schematic

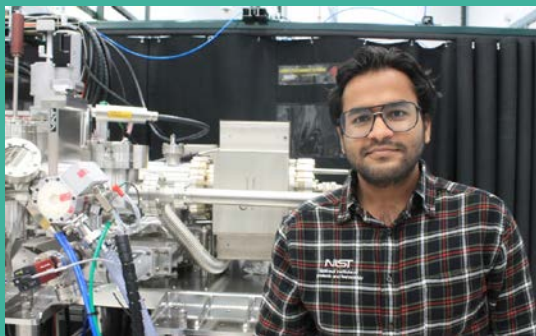


Summary

- Got 3 instruments working with the probe station
- Added documentation to code to make it easier to use and modify as needed
- Modelled and modified PEEM sample holder
- Modelled and designed PCB for sample holder

Future Work

- Adding more functionality to instruments
- Using similar code to add support for more instruments
- Manufacturing the sample holder and PCB
- Testing the PEEM and the electrical contacts



Citations

- Roussel, J-F, Faye, D., et al., "A new frontier for contamination: reaching the molecules", ISME, 2009.
- Using Nitrogen Gas in the Semiconductor Manufacturing Process | GENERON. (2020). Retrieved from <https://www.generon.com/using-nitrogen-gas-in-semiconductor-manufacturing-process/>.
- Pymasure. *Pymasure: Scientific Measurement Library for instruments, experiments, and live-plotting*. GitHub. from <https://github.com/pymasure/pymasure>

Acknowledgements

Thank you to everyone at AIP, SPS and NIST for a great summer!

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315-273-9308

Feel free to ask questions!